

Electronic Supplementary Information

Crystallization of ZnO thin films without polymer substrate deformation via thermal dissipation annealing method for next generation wearable devices

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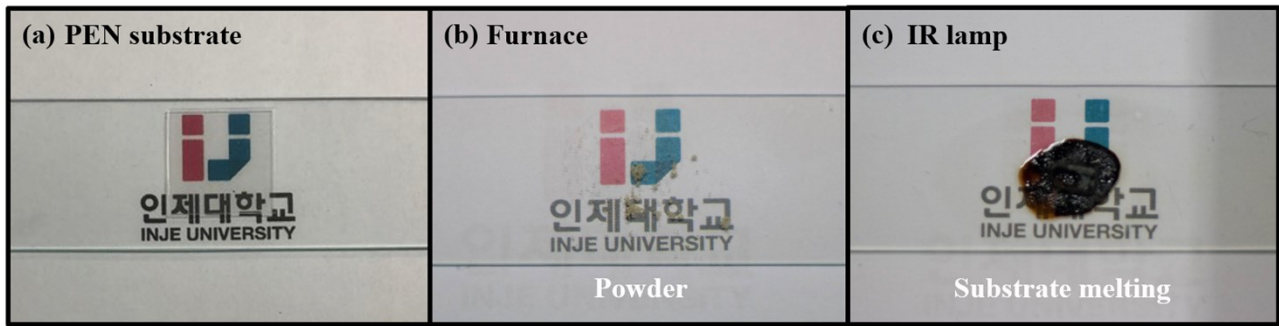


Fig. S1. Photographic image of (a) PEN substrate and sol-gel spin-coated ZnO thin films annealed by using (b) furnace and (c) IR lamp without dissipation system.